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Declaration under Rule 4.17:

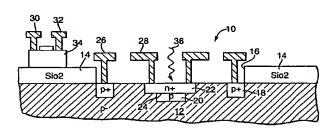
of inventorship (Rule 4.17(iv)) for US only

Published:

with international search report

[Continued on next page]

(54) Title: PHOTODETECTOR CIRCUITS



(57) Abstract: A photodetector circuit incorporates an APD detector structure (10) comprising a p- silicon handle wafer (12) on which a SiO₂ insulation layer (14) is deposited in known manner. During manufacture a circular opening (16) is formed through the insulation layer (14) by conventional photolithography and etching, and an annular p+ substrate contact ring (18) is implanted in the handle wafer (12) after opening of the window (16). The APD itself is formed by implantation of a p region (20) and an n+ region (22). After the various implantation steps a metallisation layer is applied, and annular metal contacts are formed by the application of suitable photolithography and etching steps, these contacts comprising an annular contact (26) constituting the negative terminal and connected to the p+ substrate contact ring (18), an annular metal contact (28) constituting the positive terminal and connected to the n+ region (22) of the APD, and source and drain contacts (30 and 32) connected to the source and drain of one or more CMOS MOSFET devices of the associated CMOS readout circuitry fabricated within a Si layer (34) formed on top of the insulation layer (14). Such an arrangement overcomes the problem of combining APDs with CMOS circuits in that APDs operate at relatively high reverse bias (15-30V) and CMOS circuits operate at low voltage (5V).



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 before the expiration of the time limit for amending the claims and to be republished in the event of receipt of amendments For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

(88) Date of publication of the international search report: 23 September 2004

. PATENT COOPERATION TREATY

PCT

INTERNATIONAL SEARCH REPORT

(PCT Article 18 and Rules 43 and 44)

Applicant's or agent's file reference	FOR FURTHER see Notification of Transmittal of International Search Report (Form PCT/ISA/220) as well as, where applicable, item 5 below.				
International application No.	International filing date (day/month/year)	(Earliest) Priority Date (day/month/year)			
PCT/GB 03/02851	03/07/2003	11/07/2002			
Applicant					
QINETIQ LIMITED					
according to Article 18. A copy is being tra		pority and is transmitted to the applicant			
This International Search Report consists X It is also accompanied by	or a total or	report.			
Basis of the report					
	international search was carried out on the basess otherwise indicated under this item.	sis of the international application in the			
the international search was Authority (Rule 23.1(b)).	as carried out on the basis of a translation of the	ne international application furnished to this			
b. With regard to any nucleotide and was carried out on the basis of the	d/or amino acid sequence disclosed in the in a sequence listing:	temational application, the international search			
contained in the internatio	nal application in written form.	·			
filed together with the inte	rnational application in computer readable form	n.			
furnished subsequently to	this Authority in written form.				
furnished subsequently to	this Authority in computer readble form.				
the statement that the sub international application as	sequently furnished written sequence listing do s filed has been furnished.	pes not go beyond the disclosure in the			
the statement that the info furnished	rmation recorded in computer readable form is	sidentical to the written sequence listing has been			
	nd unsearchable (See Box I).				
3. X Unity of invention is lack	king (see Box II).				
4. With regard to the title,					
X the text is approved as sul	omitted by the applicant.				
the text has been establish	ned by this Authority to read as follows:				
	omitted by the applicant. ned, according to Rule 38.2(b), by this Authorit date of mailing of this international search rep				
6. The figure of the drawings to be publi	shed with the abstract is Figure No.	2			
X as suggested by the applic	cant.	None of the figures.			
because the applicant faile	ed to suggest a figure.				
because this figure better	characterizes the invention.				
<u> </u>					

Form PCT/ISA/210 (first sheet) (July 1998)

International application No.

INTERNATIONAL SEARCH REPORT

PCT/GB 03/02851

Box III TEXT OF THE ABSTRACT (Continuation of item 5 of the first sheet)

A photodetector circuit incorporates an APD detector structure (10) comprising a p-silicon handle wafer (12) on which a SiO2 insulation layer (14) is deposited in known manner. During manufacture a circular opening (16) is formed through the insulation layer (14) by conventional photolithography and etching, and an annular p+ substrate contact ring (18) is implanted in the handle wafer (12) after opening of the window (16). The APD itself is formed by implantation of a p region (20) and an n+ region (22). After the various implantation steps a metallisation layer is applied, and annular metal contacts are formed by the application of suitable photolithography and etching steps, these contacts comprising an annular contact (26) constituting the negative terminal and connected to the p+ substrate contact ring (18), an annular metal contact (28) constituting the positive terminal and connected to the n+ region (22) of the APD, and source and drain contacts (30 and 32) connected to the source and drain of one or more CMOS MOSFET devices of the associated CMOS readout circuitry fabricated within a Si layer (34) formed on top of the insulation layer (14). Such an arrangement overcomes the problem of combining APDs with CMOS circuits in that APDs operate at relatively high reverse bias (15-30V) and CMOS circuits operate at low voltage (5V).

cternational Application No

A. CLASSIFICATION OF SUBJECT MATTER
IPC 7 H01L27/14 H01L27/146 H01L31/18 H01L31/107 According to International Patent Classification (IPC) or to both national classification and IPC B. FIELDS SEARCHED Minimum documentation searched (classification system followed by classification symbols) IPC 7 H01L Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched Electronic data base consulted during the international search (name of data base and, where practical, search terms used) EPO-Internal, WPI Data, INSPEC C. DOCUMENTS CONSIDERED TO BE RELEVANT Relevant to claim No. Citation of document, with indication, where appropriate, of the relevant passages 1-4,6-9,US 2002/024058 A1 (BIRCH STEVEN W ET AL) X 12-15, 28 February 2002 (2002-02-28) 18,19, 24,25 paragraphs '0101! - '0103!, '0110!. '0111!; claims 1,2; figures 16,19,20 20 Y 1-3,24,US 5 786 615 A (SAITO YUTAKA) X 25 28 July 1998 (1998-07-28) column 3, line 19 - column 4, line 51; figure 11 Patent family members are listed in annex. Further documents are listed in the continuation of box C. Special categories of cited documents: *T later document published after the International filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the *A* document defining the general state of the art which is not considered to be of particular relevance invention "E" earlier document but published on or after the International *X* document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such docu-ments, such combination being obvious to a person skilled O document referring to an oral disclosure, use, exhibition or document published prior to the international filing date but later than the priority date claimed *&* document member of the same patent family Date of mailing of the international search report Date of the actual completion of the international search 02/08/2004 26 July 2004 Name and mailing address of the ISA Authorized officer European Patent Office, P.B. 5818 Patentlaan 2 NL - 2280 HV Rijswijk Tel. (+31-70) 340-2040, Tx. 31 651 epo n!, Fax: (+31-70) 340-3016 Voignier, V

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C.(Continua	INTERPOLATION DOCUMENTS CONSIDERED TO BE RELEVANT	Relevant to claim No.		
Category °	Citation of document, with indication, where appropriate, of the relevant passages	Helevani to claim No.		
X	XU C ET AL: "A LOW VOLTAGE HYBRID BULK/SOI CMOS ACTIVE PIXEL IMAGE SENSOR" May 2001 (2001-05), IEEE ELECTRON DEVICE LETTERS, IEEE INC. NEW YORK, US, PAGE(S) 248-250, XP001086943 ISSN: 0741-3106 the whole document	1-3,24, 25		
Υ	FR 2 742 878 A (COMMISSARIAT ENERGIE ATOMIQUE) 27 June 1997 (1997-06-27) abstract; figure 2	20		
A	MOLONEY A M ET AL: "Small signal equivalent circuit for Geiger-mode avalanche photodiodes" 14 March 2002 (2002-03-14), ELECTRONICS LETTERS, IEE STEVENAGE, GB, PAGE(S) 285-286, XP006017928 ISSN: 0013-5194 the whole document	1-3		
A ·	NORIYOSHI YAMAUCHI ET AL: "AN INTEGRATED PHOTODETECTOR-AMPLIFIER USING A-SI P-I-N PHOTODIODES AND POLY-SI THIN-FILM TRANSISTORS" 1 March 1993 (1993-03-01), IEEE PHOTONICS TECHNOLOGY LETTERS, IEEE INC. NEW YORK, US, PAGE(S) 319-321, XP000362935 ISSN: 1041-1135 figure 2	9,15		
		,		

International application No. PCT/GB 03/02851

Box I Observations where certain claims were found unsearchable (Continuation of item 1 of first sheet)
This International Search Report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:
1. Claims Nos.: because they relate to subject matter not required to be searched by this Authority, namely:
Claims Nos.: because they relate to parts of the International Application that do not comply with the prescribed requirements to such an extent that no meaningful International Search can be carried out, specifically:
3. Claims Nos.: because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).
Box II Observations where unity of invention is lacking (Continuation of item 2 of first sheet)
This International Searching Authority found multiple inventions in this international application, as follows:
see additional sheet
1. As all required additional search fees were timely paid by the applicant, this International Search Report covers all searchable claims.
2. X As all searchable claims could be searched without effort justifying an additional fee, this Authority did not invite payment of any additional fee.
3. As only some of the required additional search fees were timely paid by the applicant, this international Search Report covers only those claims for which fees were paid, specifically claims Nos.:
4. No required additional search fees were timely paid by the applicant. Consequently, this international Search Report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.:
Remark on Protest The additional search fees were accompanied by the applicant's protest. No protest accompanied the payment of additional search fees.

FURTHER INFORMATION CONTINUED FROM PCT/ISA/ 210

This International Searching Authority found multiple (groups of) inventions in this international application, as follows:

1. claims: 1-11,18,19,24,25

A photodetector circuit including a Avalanche Photodiode comprising two regions of opposite conductivity formed in the substrate, and a readout circuit formed on an insulating layer deposited on the substrate.

A method to fabricate the photodetector circuit.

2. claims: 12-14

A photodetector circuit including a Photodiode comprising two regions of opposite conductivity formed in the substrate and one epitaxial layer formed on the substrate, and a readout circuit supported by and isolated from the substrate.

3. claims: 15-17,20-23

A photodetector circuit including a Photodiode comprising a junction formed in the substrate, and a readout circuit formed on an insulating layer deposited on the substrate, the photodiode being formed in a thinned portion of the substrate so that it can detect light incident on the back surface of the substrate.

A method of making the photodetector circuit.

Information on patent family members

International Application No

Patent document dted in search report		Publication date		Patent family member(s)	Publication date
US 2002024058	A1	28-02-2002	GB TW	2367945 A 543197 B	17-04-2002 21-07-2003
US 5786615	A	28-07-1998	JP JP EP	3363561 B2 6314699 A 0614229 A2	08-01-2003 08-11-1994 07-09-1994
FR 2742878	A	27-06-1997	FR DE DE EP WO JP	2742878 A1 69626547 D1 69626547 T2 0870335 A1 9723003 A1 2000510649 T	27-06-1997 10-04-2003 19-02-2004 14-10-1998 26-06-1997 15-08-2000